

SW Test Workshop Semiconductor Wafer Test Workshop

Automated Probe-Mark Analysis

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unec

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Overview

1. Introduction

- 2. Automated Probe Mark Recognition
- 3. Area of the Probe Mark
- 4. Results
- 5. Robustness of the algorithm
- 6. Summary



24 columns



- It is possible to probe micro-bumps directly
 - SWTW' 13: Gunther Böhm, et al.
 - SWTW' 17: Erik Jan Marinissen, et al.

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2 rows

Ø25µm Cu

Package

Substrate

6800um

Active die 3

Cu pillars / C4 bumps

Package substrate

Ball-grid array

Direct Micro-Bump Probing Need dedicated probe cards – Pyramid[®] Rocking Beam Interposer Probe Cores



RBI MEMS-type probe tips



08/17/10, 11:42 15 kV 16.5 mm 800 x 38.5 * Lowvacuum -20 um-

Quality of Probing

• Probing

Probe tips land on the probe targets (micro-bumps)

Leaves the probe marks on the micro-bumps



Probe-To-Pad Alignment (PTPA) Accuracy

Determined by probe station and probe card

- Measure probe mark offsets in all four corners of the micro-bump array
- Probe station accuracy
 - Equals offset of BL probe mark, as BL corner is main probe training location
 - Offset is chuck-position dependent
- Probe card accuracy
 - Translate offsets such that BL = (0, 0)
 - Offsets of other corners are due to probe card
 - Offsets are chuck-position independent





Motivation

- Software tool for measuring the misalignment of the probe mark w.r.t. the probe target
- Image processing for probe mark recognition
 - Contours, centers and surface areas of probe marks and probe targets
- Characterizing the quality of probing



Overview

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Area of the Probe Mark

Robustness of the algorit

Automated Probe Mark Recognition

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Image Processing Techniques

Image sharpening

- Technique for increasing image sharpness
- Edge detection
 - Algorithm: Canny¹
 - Suitable for our algorithm

Without sharpening

• With sharpening

¹John Canny, "A Computational Approach to Edge Detection", *IEEE trans. Pattern Analysis and Machine Intelligence*, 1986

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Input Files: SEM Image of Micro-Bump

Three different conditions of images for each micro-bump



Used for identifying the micro-bump contour

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mark

Contour of the Micro-Bump (1/3)
The midpoint between the leftmost and rightmost points

In theory, the midpoint is the center point of the micro-bump contour
The y position of this midpoint is incorrect.





Contour of the Micro-Bump (2/3) The contour of the micro-bump is an ellipse

We use the symmetrical property of an ellipse to determine the contour



Contour of the Micro-Bump (3/3)

Center point of the contour of the micro-bump



Probe Mark Identification Many white pixels on the edge of the probe mark White pixels on the micro-bump's contour negatively affect the result The position of the rectangle that encloses the largest amount of white pixels











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Automated Probe Mark
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Summary

Area of Probe Mark

• Determine the shape of the probe mark

Scan the edge of the probe mark

Holes inside the contour

OR

Area of Probe Mark

• Fill up the holes

Scanning along two directions





- Introduction
- Automated Probe Mark I

Robustness of the algorit

- Area of the Probe Mark
- Results

Summary

Experimental Results

Input

- Wide-I/O 2 Probe Card - 70 micro-bumps



Experimental Results

• Output



Experimental Results

• Output

offset - Notepad

File Edit Format View Help

filename:	d03_15_bl,	x_offset:	3.14727, y_offset: 4.86799, area_perct = 0.7723%
filename:	d03_15_br,	x_offset:	2.22684, y_offset: 4.27632, area_perct = 1.14631%
filename:	d03_15_t1,	x_offset:	3.59264, y_offset: 5.28053, area_perct = 0.695444%
filename:	d03_15_tr,	x_offset:	2.13777, y_offset: 5.52805, area_perct = 0.944976%
filename:	d03_22_b1,	x_offset:	4.038, y_offset: 4.00165, area_perct = 0.513286%
filename:	d03_22_br,	x_offset:	3.34716, y_offset: 3.13531, area_perct = 1.06098%
filename:	d03_22_t1,	x_offset:	4.78029, y_offset: 4.90924, area_perct = 0.0701184%
filename:	d03_22_tr,	x_offset:	3.64336, y_offset: 4.41419, area_perct = 1.09907%
filename:	d03_28_b1,	x_offset:	-0.118483, y_offset: 2.87829, area_perct = 0.914079%
filename:	d03_28_br,	x_offset:	-1.09597, y_offset: 2.26151, area_perct = 1.01705%
filename:	d03_28_t1,	x_offset:	1.06635, y_offset: 3.34158, area_perct = 1.02563%
filename:	d03_28_tr,	x_offset:	-0.473934, y_offset: 3.83663, area_perct = 1.01144%
filename:	d03_33_b1,	x_offset:	4.67262, y_offset: 5.13245, area_perct = 0.780717%
filename:	d03_33_br,	x_offset:	3.68171, y_offset: 3.89073, area_perct = 0.959621%
filename:	d03_33_t1,	x_offset:	5.7304, y_offset: 5.83609, area_perct = 0.176502%
filename:	d03_33_tr,	x_offset:	3.74109, y_offset: 5.09106, area_perct = 1.14764%
filename:	d03_37_b1,	x_offset:	1.3658, y_offset: 3.70066, area_perct = 0.812289%
filename:	d03_37_br,	x_offset:	0.504751, y_offset: 2.76403, area_perct = 1.10642%
filename:	d03_37_tl,	x_offset:	2.7019, y_offset: 4.88411, area_perct = 0.570565%
filename:	d03_37_tr,	x_offset:	0.564133, y_offset: 4.12541, area_perct = 1.27036%
filename:	d03_40_b1,	x_offset:	4.65802, y_offset: 2.42599, area_perct = 0.995459%
filename	d03_40_br	x offset.	4 25532 v offset 2 38487 area perct - 1 0748%

Automatic vs. Manual Probe Mark Analysis





Time



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Introduction

Summary

- Automated Probe Mark Red
 Area of the Probe Mark
- Results
- Robustness of the algorithm

Different Conditions of the Micro-Bump Images

- SEM tool has adjustable conditions to enhance the quality of images
- Common conditions we tried:
 - 5 contrasts: dbcc_fine, dbcc_on, dbcc_off, dbcce, eiq
 - 3 voltages: 2,000V, 5,000V, 10,000V
 - 2 frame numbers: 32 frames, 128 frames
- Goal: to check the robustness of the algorithm

Different Conditions

Contrast

- Voltage: 2,000V
- Frame: 32 frames



Different Conditions

• Voltage

- Contrast: dbcc_on
- Frame: 32 frames

• Frame

Contrast: dbcc_onVoltage: 2,000V



Results

Voltage\Contrast	dbcc_fine	dbcc_on	dbcc_off	dbcce	eiq
2,000V	C PM	C PM	C PM	C PM	C PM
5,000V	C PM	C PM	C PM	C PM	C PM
10,000V	C PM	C PM	C PM	C PM	C PM

C = micro-bump contour / PM = probe mark found / not found

Default frame setting: 32 frames
dbcc_on + 2,000V + 128 frames: C PM
All conditions use the same parameters



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Unable to handle (2/2)

Identify the probe mark

Caused by wrong contour of the micro-bump





Top-View of Micro-Bump Image

Conditions

Different contrasts with 2,000V and 32 frames





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Summary

Software tool for probe mark analysis

 Find the contour and center of the micro-bump and probe mark, and then calculate the offset between them

Comparison with manual measurements:

- More reliable
- Faster

Comes with additional features (area of probe mark)

 Robustness of the algorithm checked by using SEM images with different conditions